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PATENT APPLICATION

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Application of:)
Mitsuro SUGITA et al.) Examiner: H. Nguyen
Application No.: 09/337,040) Group Art Unit: 2851
Filed: June 28, 1999)
For: MULTIPLE EXPOSURE METHOD) October 3, 2002

Commissioner for Patents
Washington, D.C. 20231

SUPPLEMENTAL INFORMATION DISCLOSURE STATEMENT

Sir:

Further to the Information Disclosure Statements filed on December 15, 1999, and April 30, 2002, in compliance with the duty of disclosure under 37 C.F.R. § 1.56 and in accordance with the practice under 37 C.F.R. §§ 1.97 and 1.98, the Examiner's attention is directed to the documents listed on the enclosed PTO-1449 form. Copies of the listed documents are also enclosed.

Each of the cited documents was first cited in a communication from a foreign Patent Office in a counterpart foreign application not more than three months prior to the filing date of this Statement. Specifically, these documents were cited in a European Search Report dated August 23, 2002, which was forwarded in a Communication dated September 9, 2002 (copies enclosed) from the European Patent Office in a corresponding European patent application.

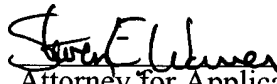
No fee under 37 C.F.R. 1.97(c)(2) is believed to be due. Nevertheless, the Commissioner may charge Deposit Account No. 06-1205, should any fee be due for filing this paper.

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Applicants request that the above information be considered by the Examiner and that a copy of the enclosed PTO-1449 form be initialed and returned indicating that such information has been considered.

Applicants' undersigned attorney may be reached in our Washington D.C. office by telephone at (202) 530-1010. All correspondence should continue to be directed to our address given below.

Respectfully submitted,



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